

# ECE-305: Spring 2018 Exam 1 Review

Pierret, *Semiconductor Device Fundamentals* (SDF)  
Chapters 1-3 (pp. 1-104)

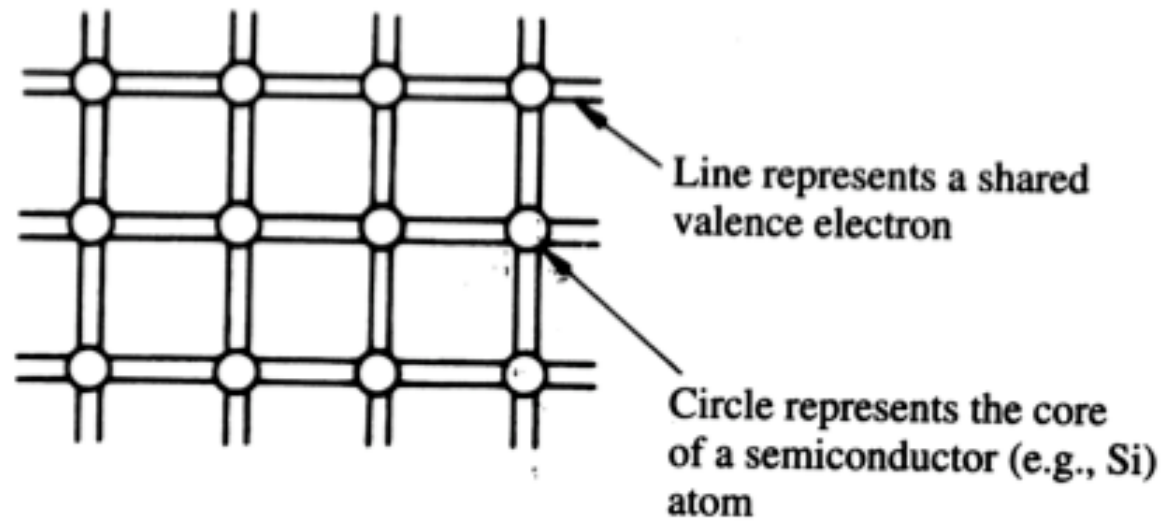
Professor Peter Bermel  
Electrical and Computer Engineering  
Purdue University, West Lafayette, IN USA  
[pbermel@purdue.edu](mailto:pbermel@purdue.edu)

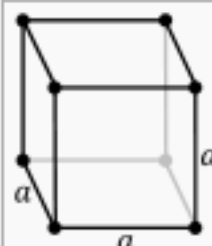
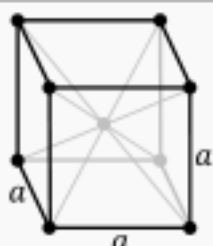
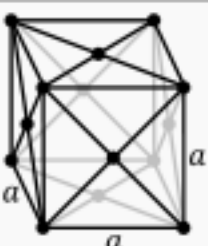
# Key concepts

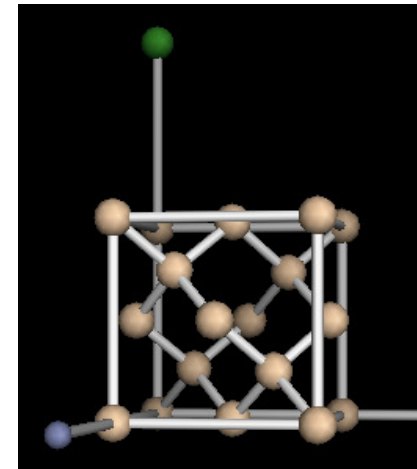
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1. Crystal structures
2. Miller indices
3. Material types + band structures
4. Carrier concentrations
5. Mobility + resistivity
6. Drift-diffusion
7. P-N Junctions

# Si crystals



	P (pcc)	I (bcc)	F (fcc)
Cubic	 <p>Diagram of a primitive cubic unit cell with side length <math>a</math>. The lattice points are at the corners of the cube.</p>	 <p>Diagram of a body-centered cubic unit cell with side length <math>a</math>. The lattice points are at the corners and the center of the cube.</p>	 <p>Diagram of a face-centered cubic unit cell with side length <math>a</math>. The lattice points are at the corners and the centers of each of the six faces of the cube.</p>



# Miller indices

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$(h\ k\ l)$  A specific plane.

$[h\ k\ l]$  A direction normal to the plane above.

$$\vec{N} = h a \hat{x} + k a \hat{y} + l a \hat{z}$$

$\{h\ k\ l\}$  A set of equivalent planes.

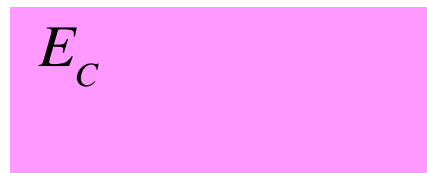
$\langle h\ k\ l \rangle$  A set of equivalent directions.

# insulators

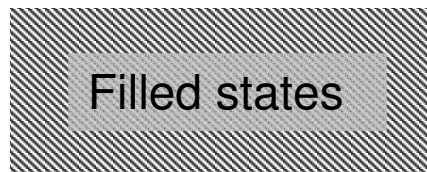
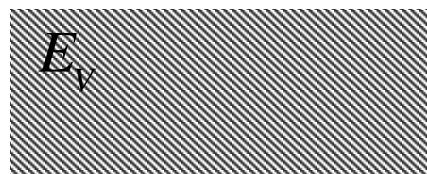
# metals

# semiconductors

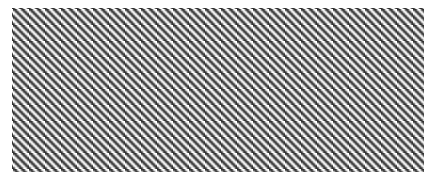
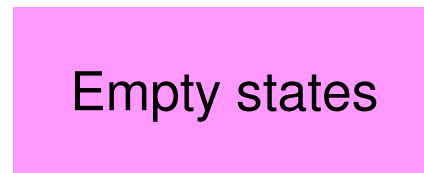
Energy



$$E_G \approx 9 \text{ eV (SiO}_2\text{)}$$



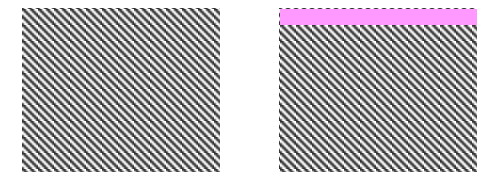
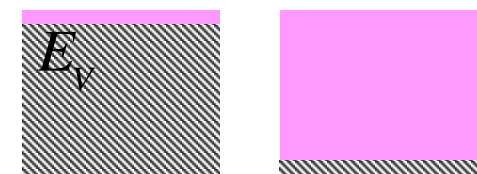
don't conduct electricity well



do conduct electricity well

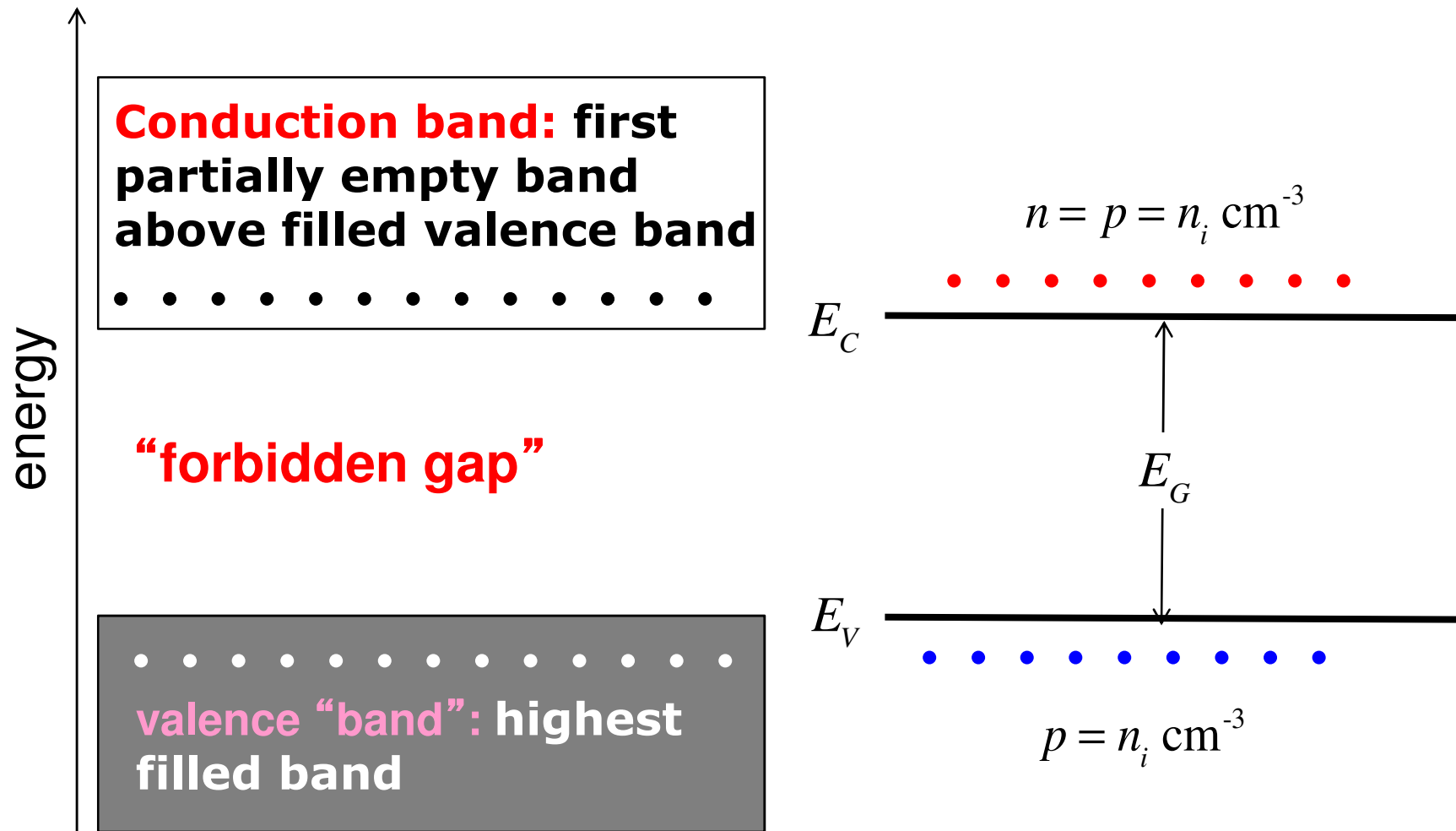


$$E_G \approx 1.1 \text{ eV (Si)}$$



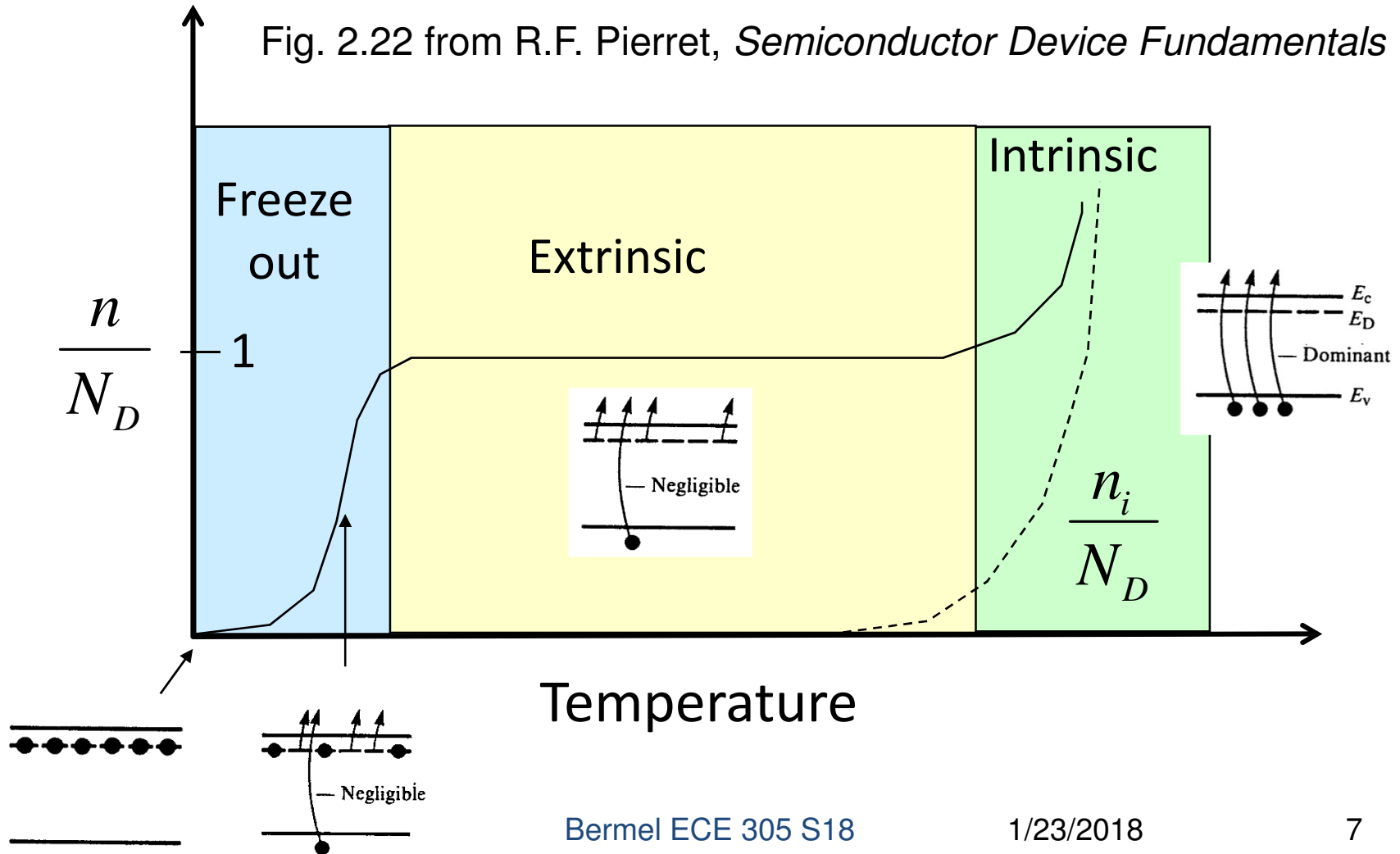
in-between, **but** can be controlled

# energy band diagrams



# Carrier concentration vs. temperature

Fig. 2.22 from R.F. Pierret, *Semiconductor Device Fundamentals*



# Carrier Concentration in Intrinsic Semiconductors

$$n = p = n_i$$

$$n \times p = N_C e^{-(E_C - E_F)/k_B T} \times N_V e^{-(E_F - E_V)/k_B T}$$

$$= N_C N_V e^{-(E_C - E_V)/k_B T}$$

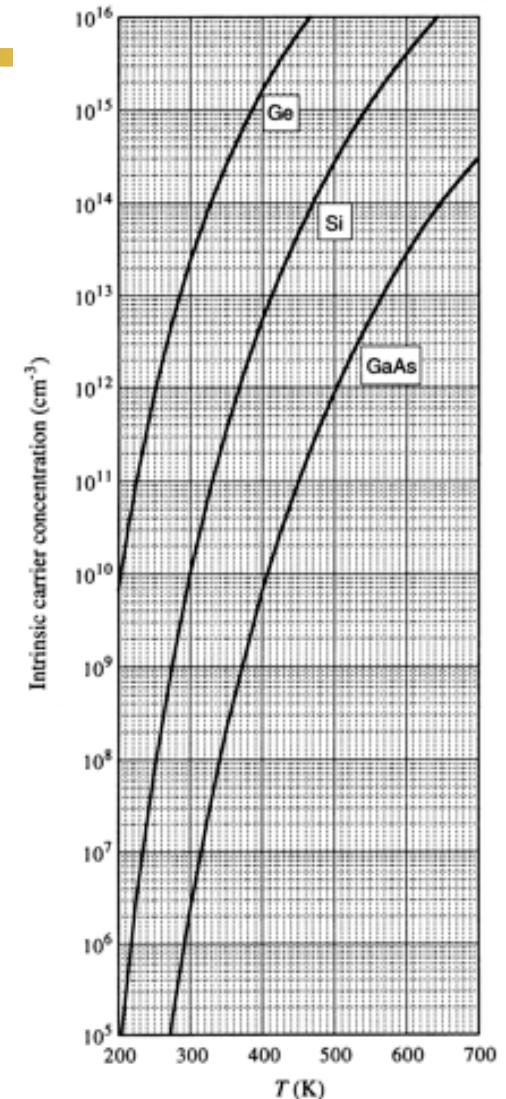
$$= N_C N_V e^{-E_g/k_B T}$$

$$= n_i^2$$

$$n_i = \sqrt{N_C N_V} e^{-E_g/2k_B T}$$

(Eq. from Ex. 2.4  
Includes temp.-dependent  
changes in effective mass)

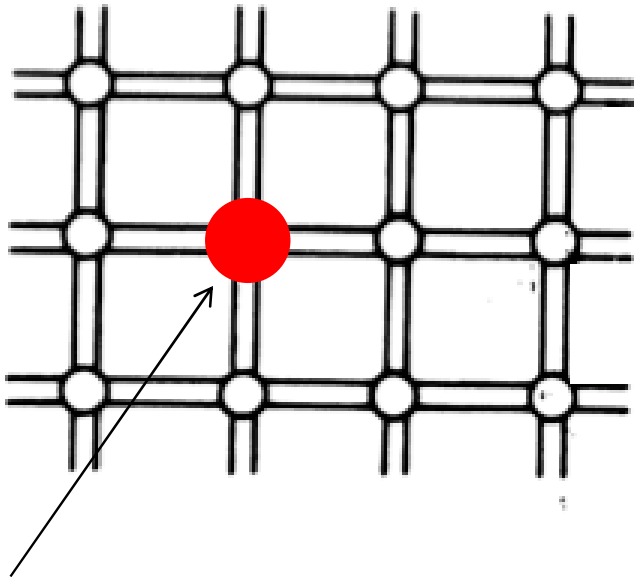
$$n_i(\text{Si}) = 9.15 \times 10^{19} \left( \frac{T}{300} \right)^2 e^{-1.12/2k_B T}$$





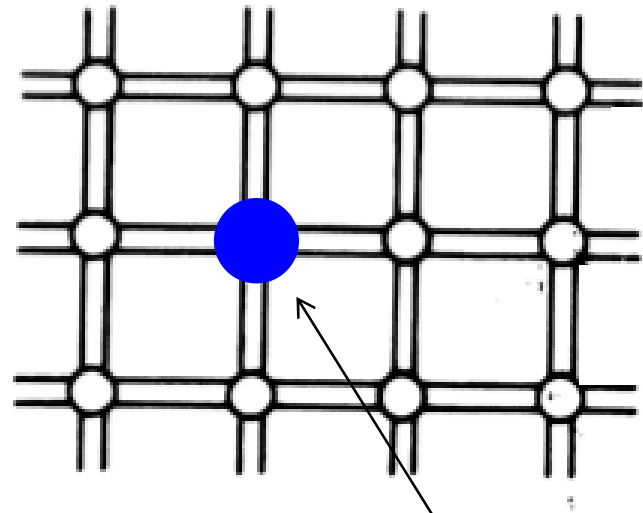
## extrinsic doping

$$n = \frac{N_D - N_A}{2} + \left[ \left( \frac{N_D - N_A}{2} \right)^2 + n_i^2 \right]^{1/2}$$



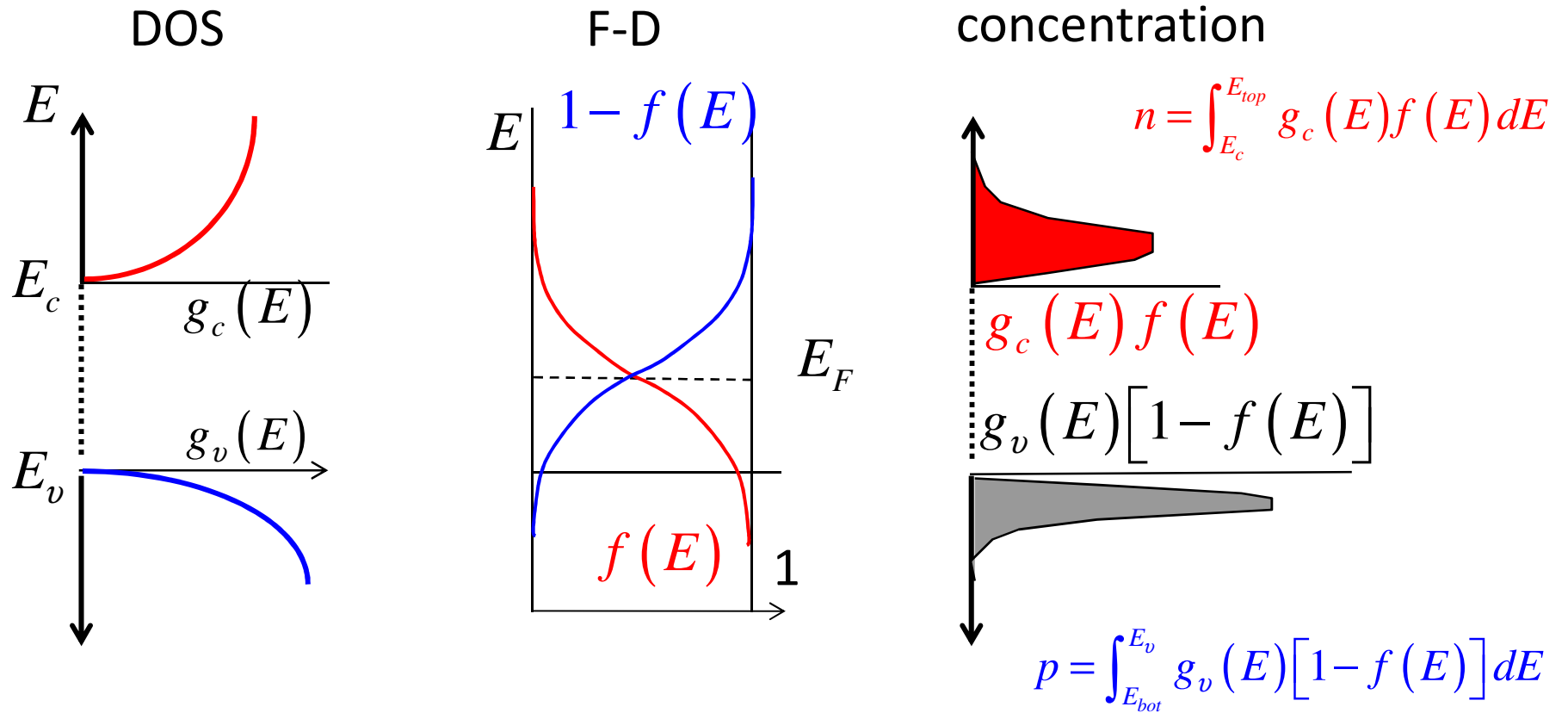
Phosphorus or Arsenic

$$p = \frac{N_A - N_D}{2} + \left[ \left( \frac{N_A - N_D}{2} \right)^2 + n_i^2 \right]^{1/2}$$



Gallium or boron

# Carrier Distribution



# current, conductivity, resistivity

$$J_{nx} = nq\mu_n \mathcal{E}_x \text{ A/cm}^2$$

$$J_{nx} = \sigma_n \mathcal{E}_x \text{ A/cm}^2$$

$$\sigma_n = nq\mu_n \text{ (units?)}$$

$$J_{px} = pq\mu_p \mathcal{E}_x \text{ A/cm}^2$$

$$J_{px} = \sigma_p \mathcal{E}_x \text{ A/cm}^2$$

$$\sigma_p = pq\mu_p$$

$$J_x = J_{nx} + J_{px} = (\sigma_n + \sigma_p) \mathcal{E}_x = \sigma \mathcal{E}_x \text{ A/cm}^2$$

$$J_x = \sigma \mathcal{E}_x \text{ A/cm}^2 \quad \mathcal{E}_x = \frac{1}{\sigma} J_x = \rho J_x \text{ V/cm}$$

$$\rho = \frac{1}{\sigma} = \frac{1}{\sigma_n + \sigma_p} = \frac{1}{nq\mu_n + pq\mu_p} \text{ } \Omega\text{-cm}$$

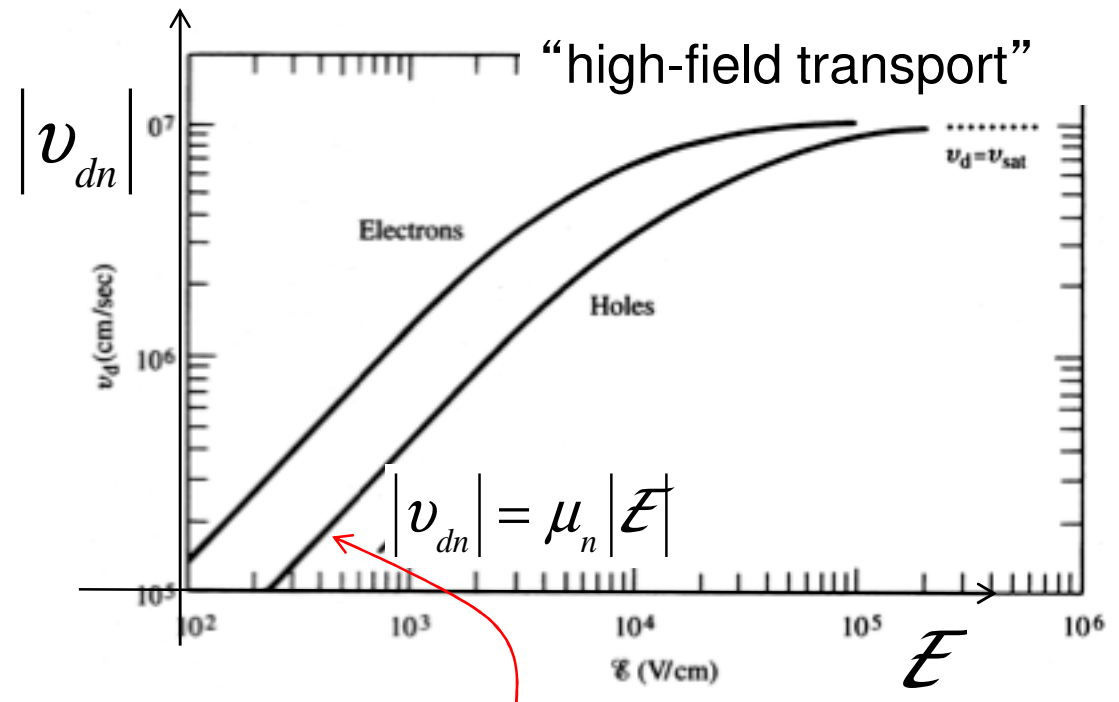
# velocity and electric field

$$v_{dn} = -\mu_n \mathcal{E}$$

$$\mu_n = \left( \frac{q\tau}{m_n^*} \right) \text{cm}^2/\text{V-s}$$

$$v_{dp} = +\mu_p \mathcal{E}$$

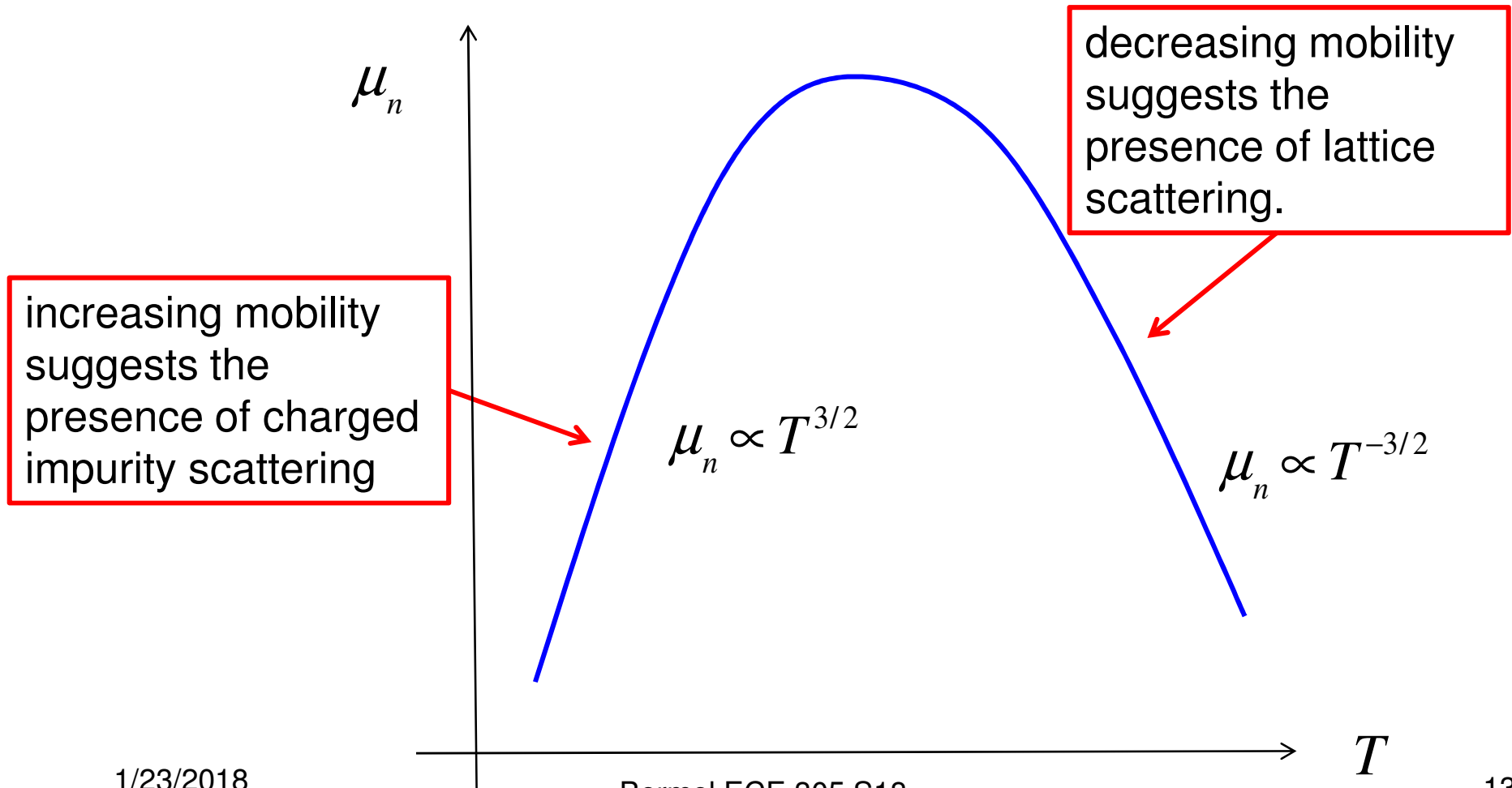
$$\mu_p = \left( \frac{q\tau}{m_p^*} \right) \text{cm}^2/\text{V-s}$$



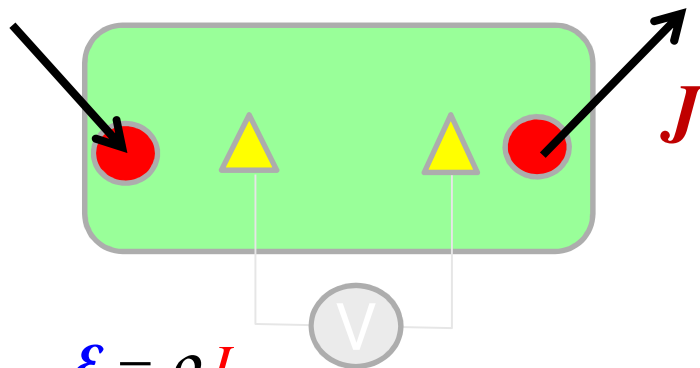
“low-field” or “near-equilibrium”  
or “linear” transport

from R.F. Pierret, *Semiconductor  
Device Fundamentals*, Fig. 3.4

# mobility vs. temperature



# Doping dependent Resistivity



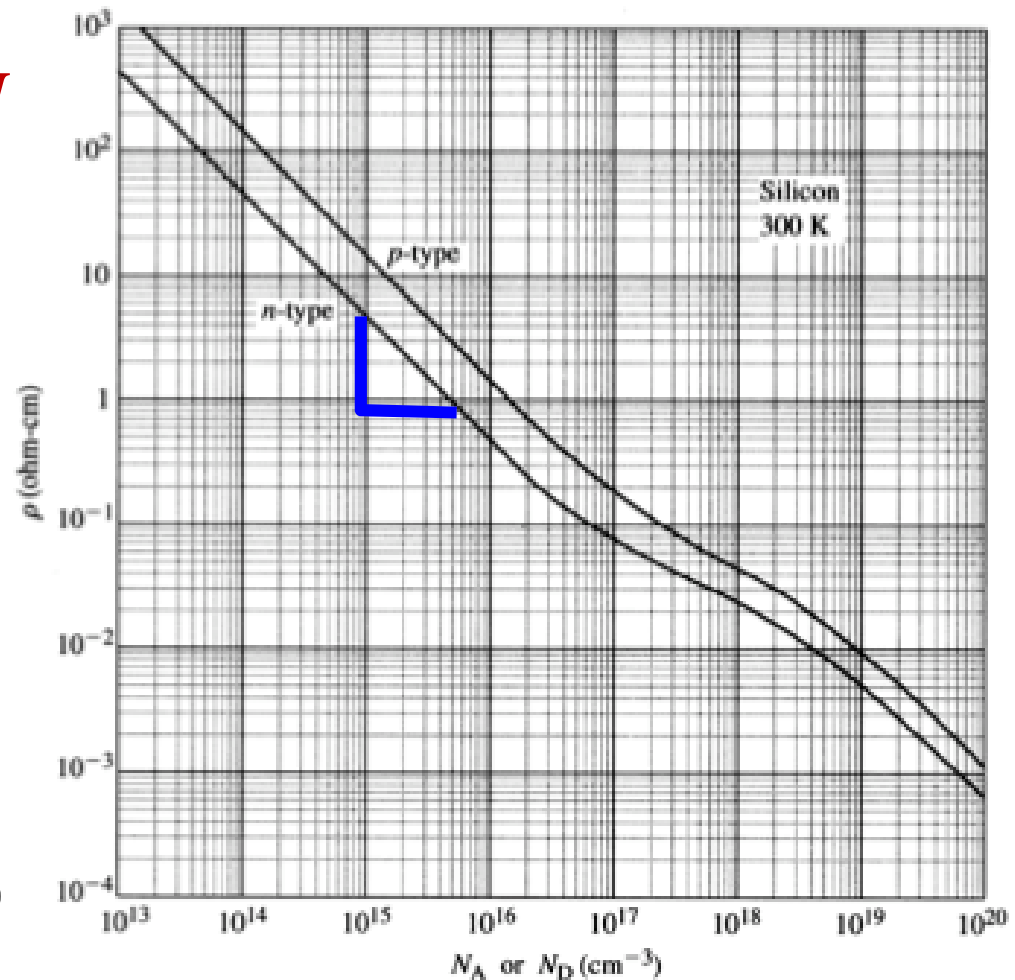
$$\mathcal{E} = \rho J$$

$$J = q(\mu_n n + \mu_p p)\mathcal{E}$$

$$\rho = \frac{1}{nq\mu_n + pq\mu_p} \Omega\text{-cm}$$

$$= \frac{1}{q\mu_n N_D} \quad (\text{for n-type})$$

$$= \frac{1}{q\mu_p N_A} \quad (\text{for p-type})$$



# drift- diffusion equation

$$\mu_p = \frac{q\tau}{m_p^*}$$

$$\mu_n = \frac{q\tau}{m_n^*}$$

$$D_p = \frac{v_{Tp} \ell_p}{2}$$

$$D_n = \frac{v_{Tn} \ell_n}{2}$$

$$\vec{J}_p = \vec{J}_{p-drift} + \vec{J}_{p-diff} = pq\mu_p \vec{E} - qD_p \vec{\nabla}p$$

current = drift current + diffusion current

$$\vec{J}_n = \vec{J}_{n-drift} + \vec{J}_{n-diff} = nq\mu_n \vec{E} + qD_n \vec{\nabla}n$$

total current = electron current + hole current

$$\vec{J} = \vec{J}_p + \vec{J}_n$$

$$D_p / \mu_p = D_n / \mu_n = k_B T / q$$

# Exam 1 Formula Sheet

Physical Constants	Silicon parameters ( $T = 300$ K)
$\hbar = 1.055 \times 10^{-34}$ J·s	$N_C = 3.23 \times 10^{19}$ cm <sup>-3</sup>
$m_0 = 9.109 \times 10^{-31}$ kg	$N_V = 1.83 \times 10^{19}$ cm <sup>-3</sup>
$k = 1.38 \times 10^{-23}$ J/K	$n_i = 1.1 \times 10^{10}$ cm <sup>-3</sup>
$q = 1.602 \times 10^{-19}$ C	$K_S = 11.8$
$\epsilon_0 = 8.854 \times 10^{-12}$ F/m	

**Miller Indices:** (hkl) {hkl} [hkl] <hkl>

**Density of states**  $g_C(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E-E_C)}}{\pi^2 \hbar^3}$

**Fermi function**  $f(E) = \frac{1}{1+e^{(E-E_F)/kT}}$

**Intrinsic carrier concentration**  $n_i = \sqrt{N_C N_V} e^{-E_g/2kT}$

**Equilibrium carrier densities:**  $N_C = \frac{1}{4} \left( \frac{2m_n^* kT}{\pi \hbar^2} \right)^{3/2}$

$N_V = \frac{1}{4} \left( \frac{2m_p^* kT}{\pi \hbar^2} \right)^{3/2}$

$n = N_C e^{(E_F-E_C)/kT} = n_i e^{(E_F-E_i)/kT}$

$p = N_V e^{(E_V-E_F)/kT} = n_i e^{(E_i-E_F)/kT}$



# Exam 1 Formula Sheet

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**Space charge neutrality:**  $p - n + N_D^+ - N_A^- = 0$

**Law of Mass Action:**  $np = n_i^2$

**Conductivity/resistivity:**  $\sigma = \sigma_n + \sigma_p = q(n\mu_n + p\mu_p) = 1/\rho$

**Drift-diffusion current equations:**  $J_n = nq\mu_n\mathcal{E}_x + qD_n\frac{dn}{dx}$        $\frac{D_n}{\mu_n} = \frac{kT}{q}$

$$J_p = pq\mu_p\mathcal{E}_x - qD_p\frac{dp}{dx} \quad \frac{D_p}{\mu_p} = \frac{kT}{q}$$

**Carrier conservation equations:**  $\frac{\partial n}{\partial t} = +\nabla \cdot \left(\frac{J_n}{q}\right) + G_n - R_n$

$$\frac{\partial p}{\partial t} = -\nabla \cdot \left(\frac{J_p}{q}\right) + G_p - R_p$$

**Poisson's equation:**

$$\nabla \cdot (\epsilon\mathcal{E}) = \rho$$

# Exam 1 Question 1 (Fall '16)

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1 (8 points). What is the difference between a metal and a semiconductor?

- a. Semiconductors have a zincblende lattice, while metals have a diamond lattice
- b. Only a semiconductor can be polycrystalline
- c. Only a metal can be polycrystalline
- d. Only a semiconductor has an electronic bandgap
- e. Only a metal has an electronic bandgap

# Exam 1 Question 2 (Fall '16)

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2 (8 points). What current is generated by holes diffusing down a concentration gradient?

a.  $+qE$

b.  $-qE$

c.  $-q D_p dn/dx$

d.  $+q D_n dp/dx$

e.  $-q D_p dp/dx$

# Exam 1 Question 3 (Fall '16)

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3 (8 points). Where are donor and acceptor levels located on an energy band diagram?

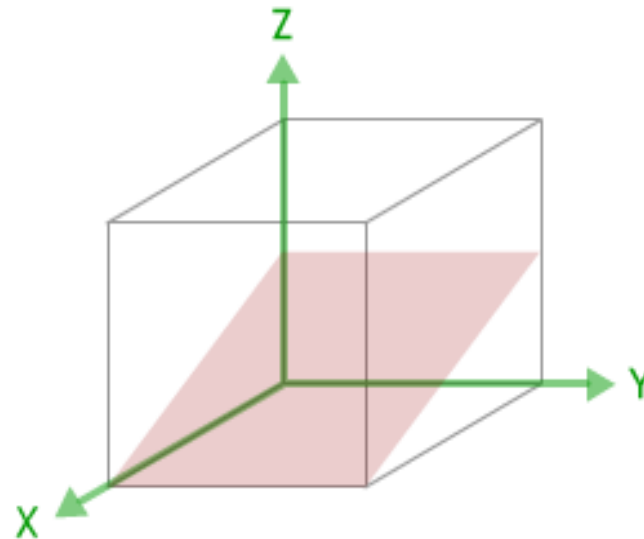
- a. Both are halfway between the conduction band minimum and valence band maximum.
- b. Just above the conduction band minimum, and just below the valence band maximum, respectively.
- c. Just below the conduction band minimum, and just above the valence band maximum, respectively.
- d. Well above the valence band maximum, and well above the conduction band minimum, respectively.
- e. Donor and acceptor levels cannot be represented on an energy band diagram.

# Exam 1 Question 4 (Fall '16)

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4 (8 points). What is the Miller index for the plane shown below?

- a. (201)
- b.  $(1\bar{1}1)$
- c. (101)
- d. (261)
- e. (102)



# Exam 1 Question 5 (Fall '16)

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5 (8 points). What is the approximate conductivity of intrinsic crystalline silicon at  $T = 300$  K? Note that  $\mu_n = 1400$  cm<sup>2</sup>/V·s, and  $\mu_p = 450$  cm<sup>2</sup>/V·s.

- a. 326 S / cm
- b. 3.26 S / cm
- c. 3.26 mS / cm
- d. 3.26  $\mu$ S / cm
- e. 3.26 nS / cm

# Exam 1 Part II (Fall '16)

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A p-type doped single-crystal wafer of germanium is at an elevated temperature ( $T = 500$  K) with intrinsic carrier concentration  $n_i = 2 \times 10^{16} \text{ cm}^{-3}$ . Assume that under these conditions, the concentration of holes  $p = 4 \times 10^{16} \text{ cm}^{-3}$  everywhere.

a. For this sample, what is the electron concentration  $n$  (in units of  $\text{cm}^{-3}$ )?

b. What is the concentration of acceptors in this material (in units of  $\text{cm}^{-3}$ )? Assume that all acceptors are fully ionized, and that the concentration of donors  $N_D = 2 \times 10^{16} \text{ cm}^{-3}$ .

# Exam 1 Part II (Fall '16)

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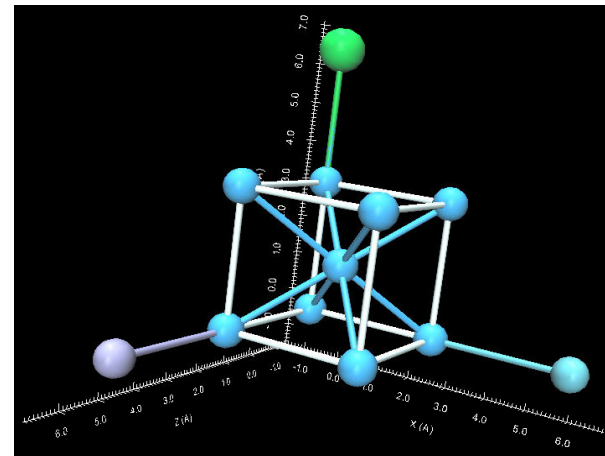
c. Calculate where the Fermi level is located with respect to the valence band (in eV). Assume that  $N_C = 2 \times 10^{19} \text{ cm}^{-3}$  and  $N_V = 10^{19} \text{ cm}^{-3}$  under the given conditions.

d. Calculate where the Fermi level is located with respect to the intrinsic level (in eV).



# Exam 1 Part III (Fall '16)

Assume that we have a body-centered cubic lattice of tungsten with an atomic radius of  $1.37 \text{ \AA}$  and a periodicity of  $3.1585 \text{ \AA}$ , as shown below (noting that  $1 \text{ \AA} = 10^{-8} \text{ cm}$ ).



- Calculate the atomic density of this material ( $\text{atoms/cm}^3$ )

# Exam 1 Part III (Fall '16)

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- b. Calculate the mass density of this material ( $\text{g}/\text{cm}^3$ ). The atomic mass of tungsten is 183.84 amu, while  $1 \text{ amu} = 1.66 \times 10^{-24} \text{ g}$ .
- c. Calculate the *packing fraction* of this material (i.e., the ratio of the total volume of the spheres to the volume of the cube enclosing them; a unitless value).

# Conclusions

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- Exam 1 takes place in class on Thursday, January 25
- Will be written to take 50 minutes, but you'll have at least 1 hour
- To do well, study Chapters 1-3; HW 1-2; Lectures 1-4; Exam 1 from prior semesters; and the notes from today